

NSF International / Nonfood Compounds Registration Program

January 26, 2001

Syneco S.p.A. Attn: Mr. Galli Via Abruzzi, 12 20098 San Giuliano, Milan, Italy

RE: Syneco Cleanair 320 F

HI

NSF Registration No. 120119

Dear Mr. Galli,

NSF has processed the application for Registration of Syneco Cleanair 320 F to the NSF Registration Guidelines for Proprietary Substances and Nonfood Compounds (2000), which are available at www.nsf.org/usda. The NSF Nonfood Compounds Registration Program is a continuation of the USDA product approval and listing program, which is based on meeting regulatory requirements for appropriate use, ingredient review and labeling verification.

This product is acceptable as a **lubricant with incidental food contact (H1)** for use in and around food processing areas. Such compounds may be used on food processing equipment as a protective anti-rust film, as a release agent on gaskets or seals of tank closures, and as a lubricant for machine parts and equipment in locations in which there is a potential exposure of the lubricated part to food. The amount used should be the minimum required to accomplish the desired technical effect on the equipment. If used as an anti-rust film, the compound must be removed from the equipment surface by washing or wiping, as required to leave the surface effectively free of any substance, which could be transferred, to food being processed.

This product is NSF Registered when the NSF Registration Number, Category Code, and Registration Mark appear on the NSF approved product label. The NSF Registration Mark can be downloaded from the NSF website, at http://www.nsf.org/mark/download_marks.html.

Registration of compounds by NSF International is in no way to be construed as an endorsement of the compounds, appropriate selection for use, or of any performance or efficacy claims made by the manufacturer.

Registration status may be verified at any time via the NSF website, at http://www.nsf.org/usda. Changes in the formulation or label, without prior written consent of NSF, will void registration, and will supersede the on-line listing.

Sincerely,

Lorelle L. Bestervelt, Ph.D.

Vice President of Technical Operations

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